

POSITIVE DECLARATION, AVAILABILITY OF DRAFT SCOPE, AND PUBLIC SCOPING SESSION

The Onondaga County Industrial Development Agency (OCIDA), as lead agency, has determined that the proposed Micron New York Semiconductor Manufacturing Action may have a significant adverse impact on the environment and a Draft Environmental Impact Statement (EIS) must be prepared. A copy of the draft scoping document and SEQRA Positive Declaration, as well as application materials and the Environmental Assessment Form, may be viewed on OCIDA's webpage: <https://www.ongoved.com/ocida/project-documents/> and the project sponsor's webpage: <http://www.micron.com/ny>. Paper copies of these documents may also be viewed at the offices of OCIDA during normal business hours by appointment by using the email address below.

A public scoping meeting will be held on Wednesday, October 11, 2023 at 6:30 p.m. pursuant to 6 NYCRR Part 617 to gather unsworn, public comment on the draft scoping document and proposed content of the Draft EIS. The meeting will take place at the North Syracuse Junior High School Auditorium, 5353 West Taft Road, North Syracuse, New York, 13212. All persons, organizations, corporations, or government agencies which may be affected by the proposed project are invited to attend the meeting and to submit oral or written comments. Although pre-registration is not required to attend the meeting, any person who wishes to speak is strongly encouraged to pre-register by 10:00 a.m. on October 10, 2023 by sending an email to micron@ongov.net.

Lengthy statements should be in writing and summarized for oral presentation. Reasonable time limits may be set for each speaker to afford everyone an opportunity to be heard. Equal weight will be given to both oral and written statements. The scoping meeting will have simultaneous Spanish and American Sign Language interpretation. Requests for additional language translation services or special needs assistance, at no charge for either service, please contact OCIDA by 5:00 p.m. October 6, 2023, using the contact information listed below.

Written comments on the draft scoping document will be accepted by OCIDA and must be submitted by mail or e-mail to the contact listed below by October 20, 2023. Written comments should be limited in content to comments on potential significant adverse impacts that should be addressed in the Draft EIS. General opposition to the proposal cannot be accommodated within the scoping document or the Draft EIS.

The Proposed Action is the development of the White Pine Commerce Park (Park), 5171 Route 31, Town of Clay, New York, by Micron New York Semiconductor Manufacturing LLC (Micron). Micron intends to invest approximately \$100 billion over the next 20 years to build a leading-edge semiconductor manufacturing campus in the Town of Clay at the expanded White Pine Commerce Park (the "Micron Campus"), which will be built-out over an approximately 20-year period with four Fabs. Micron intends to acquire the Park from the OCIDA and construct a Campus. It is expected that Fabs will be continuously fit-out and construction on the next Fab will be in sequence as the prior Fab finishes fit-out.

The Micron Campus would comprise approximately 1,400 acres, consisting of the Park previously studied by OCIDA along with additional contiguous acreage acquired or to be acquired by OCIDA. Each Fab is expected to cover approximately 1.2 million sf of land and contain approximately 600,000 sf of cleanroom space, 290,000 sf of cleanroom support space and 250,000 sf of administrative space. Each set of two Fabs will be supported by approximately 470,000 sf of central utility buildings, 200,000 sf of warehouse space, and 200,000 sf of product testing space housed in separate buildings. The Micron Campus will also have ancillary on-site electrical substations, water and wastewater treatment and storage, and industrial gas storage as well as off-site energy (natural gas and electricity), telecommunications, water, wastewater utility, and rail spur improvements.

Contact:

Onondaga County Industrial Development Agency

ATTN: Micron Project

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